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Electrochemical Deposition and Dissolution of Aluminum in NaAlCl₄ Melts

Influence of MnCl₂ and Sulfide Addition

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ABSTRACT

Effects of the additives MnCl₂, sulfide, and their combined influence on aluminum deposition and dissolution in NaAlCl₄ saturated with NaCl have been studied by polarization measurements, galvanostatic deposition, and current reversal chronopotentiometry (CRC). The solubility of MnCl₂ was found to be 0.086 ± 0.006 m/o in the melt at 175°C. Aluminum-manganese alloys can be deposited in NaAlCl₄ saturated with both NaCl and MnCl₂, resulting in a slight increase in bond energy and lattice disorder may be detected by Raman spectroscopy and STM. General agreement between the results of both analytical methods indicate that complementary information may be gained from similar studies involving graphitic structures.

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NiS$_2$) as cathode (17). MnCl$_2$, among others, was found to be the most favorable additive. In the present paper, the influences of manganese chloride, sulfide, and their combination on aluminum deposition and dissolution are presented.

**Experimental**

**Chemicals.**—The preparation of distilled aluminum chloride and dried NaCl has been described previously (18). NaAlCl$_4$ salts prepared from an equimolar mixture of distilled AlCl$_3$ and dried NaCl of analytic grade were further purified by zone refining (1). Manganese dichloride was prepared from analytical reagent MnCl$_2$-4H$_2$O by successively passing HCl gas over the solid salt at its dehydration temperatures (106° and 198°) and then through the melt at 650°C. Finally, the melt was flushed with pure N$_2$ and filtered. Sulfide in form of NaAlSCl$_2$ was prepared stoichiometrically at 250°C according to the following equilibrium (19)

$$2\text{NaCl} + \text{NaAlCl}_4 + 3\text{S} + 2\text{Al} \rightarrow 3\text{NaAlSCl}_2$$

with extra NaAlCl$_4$ as solvent.

**Electrode and cell assembly.**—A glassy carbon electrode of 3 mm diam was used as the working electrode in the deposition experiments. Aluminum electrodes of 99.999% purity were used both as counter and reference electrodes. The cell assembly and the preparation of the electrodes were the same as described in the previous paper (1).

**Instruments and measurements.**—The solubility of manganese dichloride in NaAlCl$_4$ saturated with NaCl was measured by atomic absorption analysis in combination with visual observation. The melts with excessive MnCl$_2$ were charged, evacuated, and sealed in Pyrex ampuls. At the test temperatures, the melts were maintained for 100h and then filtered through a built-in ceramic filter by turning the cell upside down. The filtered solidified melts were then analyzed.

Cathodic polarization measurements were carried out by recording a steady-state potential with a X-t recorder after setting a constant current step by step. The alloy samples were deposited onto a glassy carbon electrode. After deposition, the electrode was carefully removed from the melt, washed initially with dimethyl sulfide, then with thionyl chloride (>99%), and finally with distilled water. The composition of aluminum-manganese alloys was analyzed by EDX using a Philips SEM 505 equipped with an EDAX analyzer.

Current reversal chronopotentiometry (CRC) was performed by using a Keithley 224 Programmable Current Source. A Keithley 199 System DMM/Scanner was used to monitor the potential. All measurements were controlled by an IBM-compatible computer with a battery test program developed in this laboratory.

All experiments, deposition, current reversal chronopotentiometry, and polarization measurements were performed in a sealed Pyrex ampul. The deposits were observed by using a Zeiss Jena Technival 2 Stereo Microscope equipped with an Olympus OM-2 SLR camera and a Schott KL 1500 cold light source. The morphology of the deposits was examined by microphotography and the specific volumes of the deposits were measured as averages from the pictures.

In all melts containing MnCl$_2$, saturated concentration of MnCl$_2$ was used except for the melts containing sulfide, in the form of 1.5 m/o NaAlSCl$_2$. In the latter case the concentration of MnCl$_2$ when present was -0.1 m/o.

**Results and Discussion**

**Solubility of manganese dichloride.**—Figure 1 shows the resulting solubility of MnCl$_2$ in the NaCl-saturated NaAlCl$_4$ melt. The solubilities increase with temperature and the following relationship is obtained by regression analysis

$$S(m/o) = \frac{1}{19.44 - 0.04436t}$$

where $t$ is the temperature in °C. At 175°C the solubility is found to be 0.086 ± 0.006 m/o MnCl$_2$. In addition, the solubility of MnCl$_2$ increases with the addition of sulfide and with increasing acidity of the melt, i.e., with increasing AlCl$_3$ concentration (not shown in Fig. 1).

**Effects of MnCl$_2$ on cathodic overpotentials.**—A set of steady-state cathodic polarization curves obtained from NaCl-saturated NaAlCl$_4$ are shown in Fig. 2. In melts both with and without added MnCl$_2$, overpotentials for aluminum deposition on a glassy carbon electrode are significantly larger than that on an aluminum substrate, showing that aluminum is more easily deposited on its own base than on a foreign substrate. The presence of MnCl$_2$ in the melt results in an increase in the deposition overpotential. Stafford (13) and Hayashi (12) reported a similar increase in deposition overpotential of aluminum upon addition of MnCl$_2$ to the melt.

This phenomenon can be explained by a codeposition of manganese and aluminum. In measurements of the deposition potentials of some metals in molten NaCl-KCl-AlCl$_3$ at 156°C, Wade et al. (20) found, with a platinum reference and a platinum cathode, that the deposition potential for aluminum was -2.02V and for manganese -1.91V, respectively. Later they found, with an aluminum reference and a platinum cathode in the same melt, that the deposition potentials for aluminum and manganese were -0.02 and -0.06V, respectively (21). Such a small difference in deposition potentials clearly presents the possibility of codeposition of manganese and aluminum from the melt.

Analysis of the electrodeposits from NaAlCl$_4$ saturated with MnCl$_2$ reveals that the content of manganese in the alloy is high, especially when the mole ratio of Mn/Al in the melt is taken into account (approximately 1:10 in deposits compared with 1:550 in melts). The results are tabulated in Table I as a function of current density of deposition. The content of Mn in the deposits varied between 8 and 11 atom percent (a/o) when the current density varied from 0.29 to 2.86 mA/cm$^2$, which means that the manganese concentra...
Table I. Manganese content in electrodeposits from NaAICl₄ saturated with NaCl and MnCl₂ at 175°C.

<table>
<thead>
<tr>
<th>Current density (mA/cm²)</th>
<th>Mn content (a/o Mn)</th>
</tr>
</thead>
<tbody>
<tr>
<td>0.29</td>
<td>9.1 ± 0.5</td>
</tr>
<tr>
<td>0.43</td>
<td>7.8 ± 0.5</td>
</tr>
<tr>
<td>1.43</td>
<td>10.5 ± 1.5</td>
</tr>
<tr>
<td>2.96</td>
<td>8.3 ± 1.0</td>
</tr>
</tbody>
</table>

Morphology of deposits. — Figure 3 shows the observed different morphologies that aluminum can have when it is deposited from NaAICl₄ saturated with NaCl (first column, a-d), with added MnCl₂ (second column, e-h) at different current densities. Similarly, Fig. 4 shows the observed different morphologies that aluminum can have when it is deposited from NaAICl₄ containing sulfide (first column, i-l) and containing both sulfide and MnCl₂ (second column, m-p) at different current densities.

It was found previously (1), at lower current densities (below 0.7 mA/cm²), that many precursors for aluminum dendrites were formed initially and spongy deposits were obtained finally due to difficulties in the electronucleation process of deposition (Fig. 3a). In the intermediate range of current densities (1.0 < i < 10 mA/cm²), a smooth layer of aluminum deposits was achieved having ca. 5 times larger volume than the theoretical value (Fig. 3b). At higher current densities (>15 mA/cm²) dendritic or porous deposits often appeared (Fig. 3c and d). With addition of a small amount of manganese chloride, the precursors and finally the spongy deposits could be completely avoided, and perfectly dense deposits were obtained at lower current densities (Fig. 3e). Smooth layers of deposits were obtained at current densities up to 20 mA/cm² (Fig. 3f); however, at current densities above ca. 25 mA/cm², dendritic or porous deposits were formed (Fig. 3g and h). These dendritic deposits seemed to be different in appearance from those obtained from pure NaAICl₄. As previously demonstrated (1), spongy deposits of aluminum formed at lower current densities can be attributed to the slow rate of electronucleation involved in the deposition process. When MnCl₂ additions are present, codeposition of Al and Mn apparently promotes the nucleation, and therefore the formation of such spongy deposits is avoided.

In the melt containing 1.5 m/o NaAlSCl₂, aluminum deposits were even more spongy at lower current densities (0.285 mA/cm², Fig. 4i). This suggests that the nucleation process of aluminum deposition is more difficult in this case than in pure NaAICl₄ melts. An interesting finding is that smooth aluminum deposits, though very porous in most cases, were formed at higher current densities (Fig. 4j and k), at which dendritic deposits would be formed from...
NaAlCl₄ independent of any MnCl₂ addition. No dendrites were formed at current densities as high as 42.9 mA/cm² (Fig. 4i).

The combination of MnCl₂ and sulfide as additives to NaAlCl₄ melts resulted in a slight improvement in the spongy deposits at lower current densities (Fig. 4m) compared with those from NaAlCl₄ with (Fig. 4i) or without (Fig. 4g) sulfide. However, the deposits were far from as smooth and condensed as the deposits from NaAlCl₄ containing only MnCl₂ (Fig. 3e). Hence, the presence of sulfide in the melt destroys the effect of manganese chloride. At higher current densities no dendritic deposits were formed (Fig. 4o and p).

Figure 5 shows specific average volumes of electrodeposits obtained from the NaCl-saturated NaAlCl₄ without any additives compared with melts containing manganese chloride, sulfide, and both manganese chloride and sulfide additives. Each point is the average value of at least two measurements. At low current densities, the high values of specific volumes of deposits from the NaAlCl₄ melts and melts containing sulfide indicate the formation of spongy deposits. The volumes of deposits from melts saturated with MnCl₂ were close to the theoretical value, indicating formation of perfectly compact deposits of aluminum-manganese alloys.

At intermediate current densities, the volumes of deposits from NaAlCl₄ melts and melts containing sulfide and sulfide-manganese chloride in combination were approximately equal and were about five times larger than the theoretical value. Deposits from the melts containing only manganese chloride were significantly more compact, especially at lower current densities.

Current reversal chronopotentiometry.—Current reversal chronopotentiometry was used to investigate the reversibility of aluminum deposited in NaAlCl₄ melts with addition of MnCl₂, sulfide, and their combination. 1 C/cm² was applied in each deposition. In order to study the effects of the deposition current on the reversibility of aluminum deposition, an arbitrary constant current of 0.714 mA/cm² was used to reoxidize the aluminum deposited at different current densities. A set of chronopotentiograms at a current density of 0.714 mA/cm² for both deposition and reoxidation is shown in Fig. 6.

As can be seen from Fig. 6, overpotentials of reoxidation are much higher for the aluminum-manganese alloy than for pure aluminum. When aluminum or aluminum-manganese alloy was being reoxidized upon reversal current, the electrode potential was almost constant or increased slightly. When this process was complete, the potential rose rapidly to that of chlorine evolution (at ca. 2.3 V vs. aluminum reference). The transition time was determined from the potential-time curves by extrapolation of the maximum slope at the completion of reoxidization. The coulombic efficiency (charge ratio of reoxidation to deposition) was thus calculated, as shown in Fig. 7.

All values of coulombic efficiencies were less than unity. This has earlier, in both NaCl-AlCl₃ (24) and organic aluminum chloride (25-27), been attributed to the corrosion of aluminum by impurities. In the present study, it was found that this phenomenon was mainly dependent on the interfacial properties between deposits and the electrode, i.e., the adhesion of deposits to the substrate. Through a microscope, it was observed that some forms of small aluminum pieces fell off into the melt during reoxidization, and small aluminum particles remained on the electrode surface during chlorine gas evolution, apparently not adhering well to the electrode.

It can be seen from Fig. 7 that coulombic efficiencies of more than 95% were obtained at low deposition current densities in NaAlCl₄ melts both with and without MnCl₂. The coulombic efficiency decreased with increasing deposition current density, more significantly in the melt containing manganese dichloride than in the pure NaAlCl₄ melt. Addition of sulfide resulted in much lower coulombic efficiencies (with a maximum at a current density of ca. 0.7 mA/cm²). The addition of MnCl₂ to the melts already containing sulfide considerably improved the cou-
Coulombic efficiencies, although not as much as without sulfide. An investigation on the mechanism, using several different substrates such as copper, tungsten, nickel, etc., is underway (28).

Conclusions

The solubility of manganese dichloride was found to be 0.086 ± 0.006 m/o in NaAlCl4 saturated with NaCl at 175°C. The addition of such small quantity of MnCl2 to NaAlCl4 melts saturated with NaCl leads, upon electrolysis, to a co-deposition of aluminum-manganese binary alloys, resulting in a formation of smooth, compact deposits at low current densities, below 6 mA/cm2. Dendritic deposits of the alloy were formed at high current densities, above 25 mA/cm2.

The presence of sulfide in NaAlCl4 melts tends to cause spongy deposits, and therefore, when both additives are present, destroys the beneficial effects of MnCl2 at lower current densities. At high current densities, however, it prevents dendrite formation.

Cathodic overpotentials of the codeposition of Al-Mn alloys are slightly higher than that of pure aluminum deposition, and overpotentials are ca. 60 mV higher at a glassy carbon electrode than at an aluminum electrode in melts both with and without MnCl2.

Coulombic efficiencies by CRC measurements are high at lower current densities but decrease with increasing current density of deposition. In the melts containing sulfide, coulombic efficiencies are extremely low. In all cases, coulombic efficiencies were found to be less than unity, mainly due to the bad adhesion of the deposits to the substrate. Further investigations are planned by using different substrates.

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Technical Notes

A Three-Phase Fluidized Bed Fuel Cell

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Flat porous electrodes are presently used in fuel cells, but they require careful porosity control, resulting in a complex production process. The development of a new type of electrode with a simpler structure as well as a larger effective area would be desirable.

This study proposes a three-phase fluidized bed electrode that can be used in simple electrode alkaline fuel cells. There are several publications on fluidized bed electrodes that combine two liquid phases or a solid and a liquid phase (1, 2). However, we have not found any publication on three-phase fluidized bed electrodes that combine solids, liquids, and gases. The electrode structure consists of a glass tube containing an electrolyte solution and catalytic particles. Hydrogen or oxygen gas is introduced into the tube from the bottom, while the solution and catalyst are agitated in the fluidized bed. Under these conditions,